

Kathleen (Kat) Lynch

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Overview

Kathleen is a skilled patent and trademark litigator and enforcement strategist. She represents businesses of all sizes, as plaintiffs and defendants, resolving their disputes at the U.S. Patent & Trademark Office, before the International Trade Commission (ITC), and in district courts.

Articulate, diligent, and a natural problem-solver, Kat is known for her analytical abilities, meticulous research and strong writing skills. She excels at crafting persuasive arguments and is experienced in drafting cease-and-desist letters, takedown requisitions and other mechanisms to safeguard her clients' IP rights. Working closely with industry experts, she ensures complex technical topics are clearly communicated to judges and juries.

Kat is also dedicated to pro bono efforts, providing support to individuals seeking asylum and assisting them with affirmative asylum applications.

Credentials

EDUCATION

- Case Western Reserve University School of Law, 2022, J.D., *magna cum laude*
  - Order of the Coif
  - Publisher, Case Western Law Review
- University at Buffalo, 2019, M.S., Library and Information Sciences

- Wesleyan University, 2013, B.A., English and Spanish Literature
  - With honors

BAR & COURT ADMISSIONS

- Illinois

Memberships

- Chicago Bar Association
- Chicago Women in IP
- Intellectual Property Law Association of Chicago (IPLAC)
- Planning Committee Member, ChiWIP

News & Insights

- Benesch Represents ASUSTeK in Federal Patent Appeal - Featured in Law360
  June 18, 2025 | Media Mentions
- Kathleen Lynch Mentioned in Crain's Chicago People on the Move
  December 10, 2024 | Media Mentions